Proposal of new service: mask correction

- Wafers in Backup are wafers stopped at Poly layer (no backend metal layers).
- Lead-time for reprocessing is within few weeks, instead of submitting a new version in a new MPW run and waiting for a full process,
- When available, they can be used for metal fix (correction of metal / via layer masks).

Some Rules:
- Wafers in backup can only be used within 12 months after fab-out.
- Can be ordered with a minimum lot of 6 wafers.
- Backup wafers can be scheduled on request if the quantity fits in the start-plan.
- Metal / Via new masks are charged.

- At ams, wafers in backup have to be ordered and bought at the time of start of MPW runs.
- At ST, wafers in backup could sometimes be available, even if not ordered in advance. Otherwise, wafers have to be ordered and bought at the time of start of MPW runs.

Contact us for more information on wafers in backup.
Proposal of new service: IP sharing

- Do you need a specific IP or need help on a specific design flow?
- Do you own an IP or a design-flow and want to share it?

You can ask CMP either to publish your IP, or to publish your request for IP.

Proposed tools:
- List of IPs available in a FAQ at CMP support center web site.
- Mailing list which from time to time could be used for a call for IP
- Gallery of circuits made previously (published by CMP users).